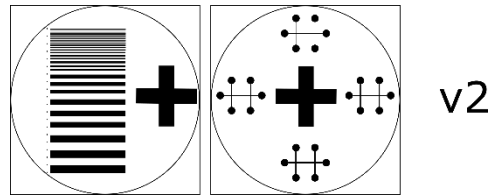


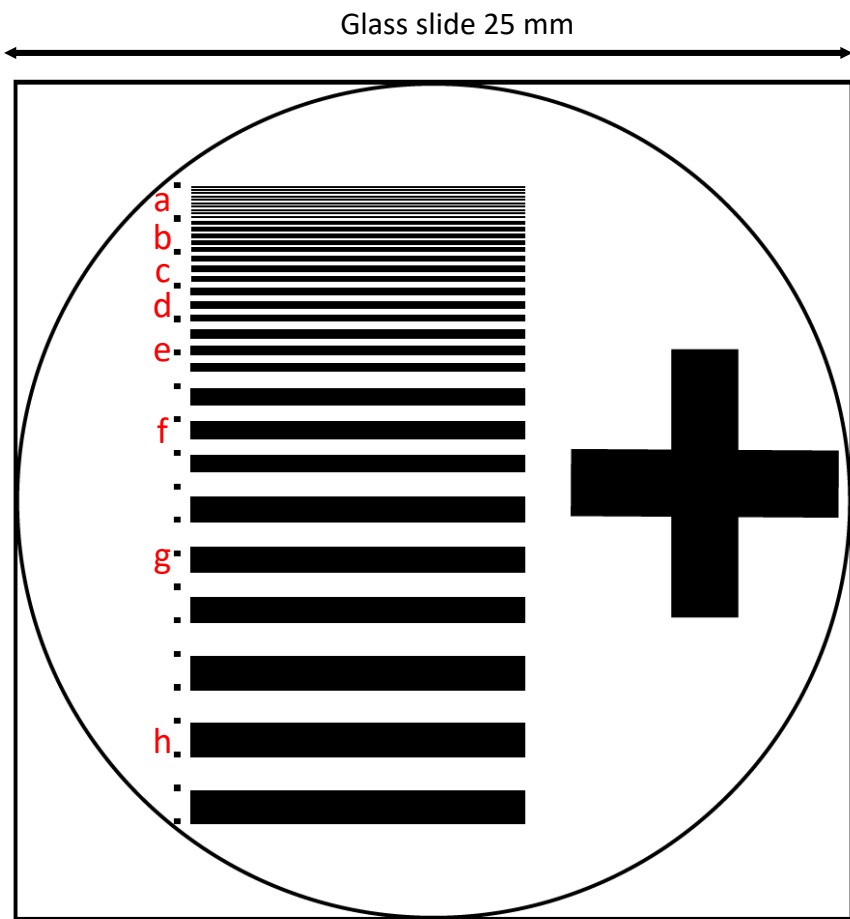
Patterns for Projection Photolithography

Details about pattern

“Photolithography masks_v2.svg”

original size png



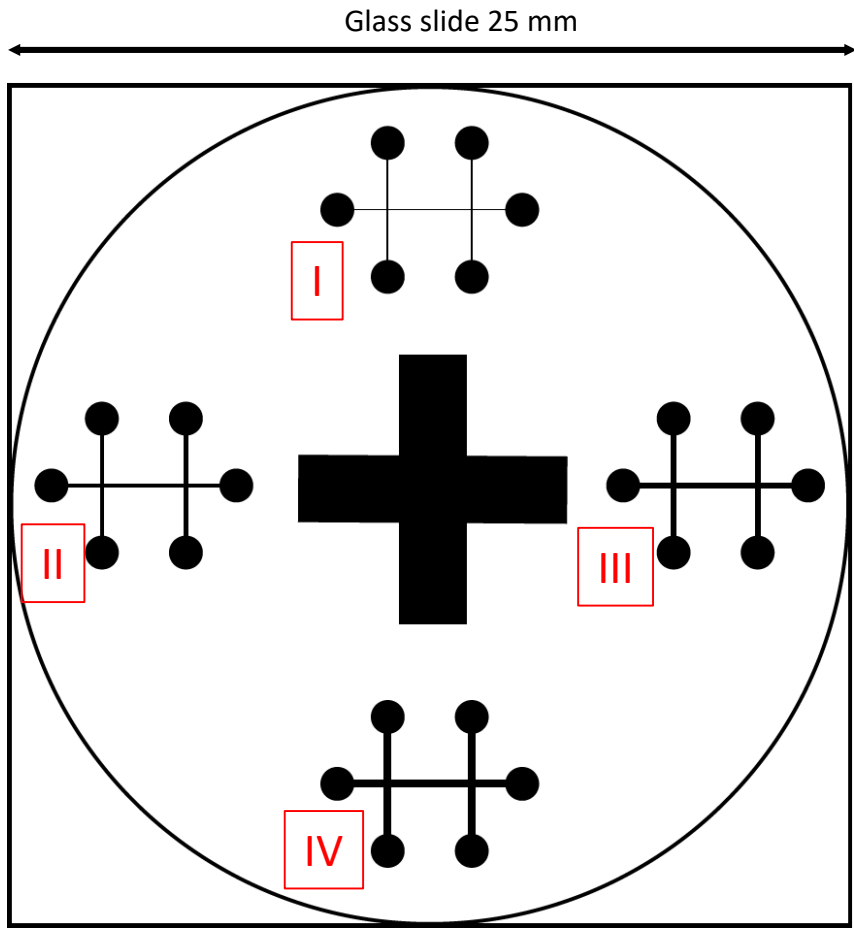


Lines Feature	w (μm)	s (μm)	repeated over
a	50	50	1 mm
b	100	100	1mm
c	150	150	1mm
d	200	200	3x
e	250	250	3x
f	500	500	3x
g	750	750	3x
h	1000	1000	3x

(magnified png)

Length: 10 mm

Cross (focusing feature) lines: 2 x 8 mm



Lines Feature	w (μm)
I	50
II	100
III	150
IV	200

(magnified pdf)

Cross (focusing feature) lines: 2 x 8 mm

